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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/606,823	06/26/2003	Shih-Ming Chang	67,200-1010 5507		
7590 07/13/2006			EXAMINER		
TUNG & ASSOCIATES Suite 120			GARCIA, JOANNIE A		
838 W. Long Lake Road			ART UNIT	PAPER NUMBER	
Bloomfield Hill		2823			

DATE MAILED: 07/13/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

		A 12 42	- 65-	A 4:	-\\\				
		Application	n No.	Applicant(s)	C				
Office Action Summary		10/606,82	3	CHANG ET AL.					
		Examiner		Art Unit					
		Joannie A.	García	2823					
D 1.6.	The MAILING DATE of this communication	on appears on the	cover sheet with the c	correspondence addre	ess				
Period fo	• •				-				
WHIC - Exte after - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR F CHEVER IS LONGER, FROM THE MAILII nsions of time may be available under the provisions of 37 of SIX (6) MONTHS from the mailing date of this communicate Depriod for reply is specified above, the maximum statutory are to reply within the set or extended period for reply will, by the reply received by the Office later than three months after the ed patent term adjustment. See 37 CFR 1.704(b).	NG DATE OF TH CFR 1.136(a). In no eve ion. period will apply and wi y statute, cause the appl	IS COMMUNICATION Int, however, may a reply be tire I expire SIX (6) MONTHS from ication to become ABANDONE	N. nely filed the mailing date of this comr D (35 U.S.C. § 133).					
Status									
1)⊠	Responsive to communication(s) filed on	13 April 2006.							
2a)⊠									
3)	, —								
,_	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.								
Disposit	ion of Claims								
4)⊠	4)⊠ Claim(s) <u>24-39</u> is/are pending in the application.								
,—	4a) Of the above claim(s) is/are withdrawn from consideration.								
5)⊠	Claim(s) 39 is/are allowed.								
6)⊠									
7)									
8)[Claim(s) are subject to restriction	and/or election re	equirement.						
Applicat	ion Papers								
9)[The specification is objected to by the Ex	aminer.							
10)	The drawing(s) filed on is/are: a)[\square accepted or b)	objected to by the	Examiner.					
	Applicant may not request that any objection								
	Replacement drawing sheet(s) including the								
11)	The oath or declaration is objected to by	the Examiner. No	ote the attached Office	Action or form PTO	9-152.				
Priority	under 35 U.S.C. § 119								
	Acknowledgment is made of a claim for for All b) Some * c) None of: 1. Certified copies of the priority doc			n)-(d) or (f).					
	2. Certified copies of the priority doc			tion No					
	3. Copies of the certified copies of the application from the International I	ie priority docum Bureau (PCT Rul	ents have been receiv e 17.2(a)).	ed in this National S	tage				
*	See the attached detailed Office action for	r a list of the cert	fied copies not receiv	ed.					
Attachme	nt(s)								
	ce of References Cited (PTO-892)	4) Interview Summar Paper No(s)/Mail I							
3) 🔲 Info	ce of Draftsperson's Patent Drawing Review (PTO-S rmation Disclosure Statement(s) (PTO-1449 or PTO er No(s)/Mail Date			Patent Application (PTO-	152)				

Application/Control Number: 10/606,823

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The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

Claims 24-38 are rejected under 35 U.S.C. 102(b) as being anticipated by Higashikawa et al (U.S. Patent 6,319,637).

Higashikawa et al discloses a lithographic semiconductor fabrication process comprising exposing a semiconductor wafer to a first mask part that comprises a layout for a semiconductor device that is at least defective to form a defectively exposed portion (Figure 2A, and Column 7, lines 7-10), exposing the defectively exposed portion to a second mask part corresponding to the first mask part substantially free from defects that comprises another layout for the semiconductor device that is at least free from defects, a second and a third time (Figures 2A-2C, and Column 7, lines 35-67), wherein the first and second mask parts are formed on a same photomask (Figure 2A), and wherein said first mask part and said second mask part are on different photomasks (Figures 2C-2D, and 3A-3B, Column 5, lines 7-8, and Column 7, lines 35-67), exposing the defectively exposed portion to a third mask part one or more times (Figures 2A-2E), exposing the defectively exposed portion to the second mask part a second and a third time, or one or more times (Column 7, lines 45-67), and exposing the defectively exposed portion to the second, a third and other additional mask parts one or more additional times (Figures 2A-2E, and Column 7, lines 21-67).

Applicant argues that Higashikawa et al does not teach exposing the wafer to a first mask part that is at least partially defective to form a defectively exposed portion, and exposing the defectively exposed portion to a second mask part corresponding to the

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first mask part at least substantially free from defects. However, Higashikawa et al discloses exposing the wafer to a first mask part that is at least partially defective to form a defectively exposed portion, and exposing the defectively exposed portion to a second mask part corresponding to the first mask part at least substantially free from defects (Figures 2A-2C, and Column 7, lines 7-10, and 35-67).

Claim 39 is allowed.

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Joannie García whose telephone number is (571) 272-1861. The examiner can normally be reached on Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Smith, can be reached on (571) 272-1907. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

George Fourson Primary Examiner Art Unit 2823 Page 4

JAG July 8, 2006

GFourson Primary Examiner